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WITH n-BUTYLLITHIUM .

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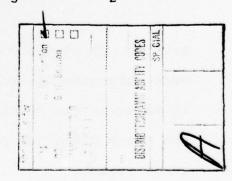
THE REACTION OF 3,3-DICHLOROALLYLTRIMETHYLSILANE WITH n-BUTYLLITHIUM.

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SUMMARY

<u>n</u>-Butyllithium reacts with 3,3-dichloroallyltrimethylsilane to metalate the vinyl proton. Under the reaction conditions the Me₃SiCH₂C(Li)=CCl₂ formed undergoes β-elimination of LiCl to give ClC=CCH₂SiMe₃ whose subsequent reaction with <u>n</u>-butyllithium produces LiC=CCH₂SiMe₃. Addition of trimethylchlorosilane gives Me₃SiC=CCH₂SiMe₃. When two molar equivalents of <u>n</u>-butyllithium are used, further metalation of LiC=CCH₂SiMe₃ gives LiC=CCH(Li)SiMe₃. The action of N-bromosuccinimide on Me₃SiCH₂CH=CCl₂ resulted in formation of Me₃SiCH=CHCCl₂Br.



[#] National Science Foundation Granuate Fellow, 1973-1976.

INTRODUCTION.

In a recent investigation, we prepared the novel ambident allylic lithium reagent gem-chloro(trimethylsilyl)allyllithium, was prepared to reactions with a variety of substrates was studied.

Another trimethylsilyl-substituted allyllithium reagent which was of potential interest to us was II, and we report here con-

cerning our attempts to prepare this reagent. Although they were unsuccessful, the route examined was of interest since it involved the reaction of <u>n</u>-butyllithium with a molecule which had three different potential sites at which the lithium reagent could attack.

RESULTS AND DISCUSSION.

The organosilicon compound which was chosen as a potential precursor for II was 3,3-dichloroallyltrimethylsilane,

Me₃SiCH₂CH=CCl₂.* This was readily prepared. The condensation of trichlorosilane with 1,1,3-trichloropropene by the method of Furuya and Sukawa² (eq. 1) gave Cl₃SiCH₂CH=CCl₂ whose methylation

$$cl_2c = chch_2cl + hsicl_3 + Et_3N \xrightarrow{Cucl} cl_3sich_2ch = ccl_2 + Et_3NH^+cl^-$$

$$Et_2O$$
(1)

with methylmagnesium bromide produced the desired silane.

The hoped-for reaction of $Me_3SiCH_2CH=CCl_2$ with <u>n</u>-butyllithium is the one shown in eq. 2. Metalation α to a silyl group is a

$$\text{Me}_3 \text{SiCH}_2 \text{CH=CCl}_2 + \text{n-C}_4 \text{H}_9 \text{Li} \longrightarrow \text{Li}[\text{Me}_3 \text{SiCHCHCCl}_2] + \underline{\text{n-C}}_4 \text{H}_{10}$$
 (2)

favorable process since silicon stabilizes an adjacent negative charge. In fact, trimethylsilylallyllithium, Li[Me₃SiCHCHCH₂], is readily prepared by reaction of allyltrimethylsilane with n-butyllithium. However, the two chlorine atoms in Me₃SiCH₂CH=CCl₂ also will have activating effects on the attack by n-butyllithium, and these will oppose the desired metalation process. On the one hand, they will enhance the acidity of the vinyl proton,

^{*} The action of n-butyllithium on the isomeric $\text{Me}_3\text{SiCCl}_2\text{CH=CH}_2$ was reported in ref. 1.

making it more reactive toward a base; on the other hand, the two chlorine substituents will mutually enhance each other's reactivity toward lithium/chlorine exchange with an alkyllithium. Thus Me₃SiCH₂CH=CCl₂ offers three potential sites for attack by n-butyllithium.

In the initial experiment, a molar equivalent of n-butyl-lithium in hexane was added to a solution of Me₃SiCH₂CH=CCl₂ in tetrahydrofuran (THF) which was cooled to -90°. After 30 min., an excess of trimethylchlorosilane was added to the reaction mixture. The products were an acetylenic silane, 2,2,6,6-tetramethyl-2,6-disila-3-heptyne, Me₃SiC=CCH₂SiMe₃, in 26% yield, and 2,2,6,6-tetramethyl-2,6-disila-3-chloro-3-heptene, Me₃SiC(Cl)=CH-CH₂SiMe₃, in 6% yield. A 68% recovery of the starting silane was realized.

Further experiments (Table 1) showed that longer reaction times or higher temperatures increase the yield of the acetylene. The last three experiments show roughly the same result, that just over one-half of the starting material is converted to the acetylene. Apparently, the conditions of the first experiment did not allow the reaction to go to completion.

The fact that about one-half of the starting material remains unreacted suggests that two molar equivalents of n-butyllithium are consumed per equivalent of substrate. However, doubling the amount of the lithium reagent caused more deprotonation of the substrate, and on reaction of the organolithium intermediates with trimethylchlorosilane, 1,3,3-tris(trimethylsily1)propyne, Me₃SiC=CCH(SiMe₃)₂, was formed in 19% yield,

TABLE 1. Reactions of 3,3-Dichloroallytrimethylsilane with One Molar Equivalent of n-Butyllithium. Trimethylchlorosilane Quench.

Reaction Reaction		Relative Yields*		
Temperature, °C	°C Time, min.	Me₃SiC≅CCH₂SiMe₃	Me ₃ SiCH ₂ CH=CCl ₂	
000		2644	6044	
-90°	30	26**	68**	
-90°	150	59	41	
-46°	30	55	45	
- 1°	30	53	47	

^{*} Relative ratio determined by GLC.

^{**} Absolute yield determined by GLC (internal standard method).

in addition to $\text{Me}_3\text{SiC}\cong\text{CCH}_2\text{SiMe}_3$ (37%). Such multiple substitution had been observed by West et al.⁶, who obtained the same tris-(trimethylsilyl)propyne in a reaction of an excess of <u>n</u>-butyl-lithium with propyne with subsequent addition of trimethyl-chlorosilane.

These observations are explicable in terms of initial metalation of the vinyl proton of $\text{Me}_3\text{SiCH}_2\text{CH=CCl}_2$. Previous work reported by Köbrich and his coworkers $^{7-9}$ is pertinent. Low temperature reactions of <u>n</u>-butyllithium with equimolar quantities of mono-, di-(<u>cis-</u> and <u>trans-</u>) and trichloroethylene were found to result in metalation of the vinylic hydrogens to give α -chlorovinyllithium compounds (eq. 3). The stabilities of

(R,R' = H and/or Cl)

these products depended on their configuration. The least stable were those with vicinal chlorine and lithium substitution in trans relationship. These decomposed by trans-elimination to give an acetylene (eq. 4). In those cases where a chloro-

$$\begin{array}{c}
R \\
C = C
\end{array}$$

$$\begin{array}{c}
R \\
C = CR' + LiC1
\end{array}$$
(4)

(R,R' = H and/or Cl)

acetylene was produced, further reaction with n-butyllithium gave

alkynyllithium reagents. Such chemistry is involved in the $Me_3SiCH_2CH=CCl_2/\underline{n}-C_4H_9Li$ interaction.

The initial step must be metalation (eq. 5). The product

undergoes $trans-\beta$ -elimination of lithium chloride (eq. 6).

The chloroacetylene produced reacts with \underline{n} -butyllithium, giving Li/Cl exchange (eq. 7). The reaction sequence (5,6,7) utilizes

$$\text{ClC=CCH}_{2}\text{SiMe}_{3} + \underline{\text{n}}\text{-C}_{4}\text{H}_{9}\text{Li} \longrightarrow \text{LiC=CCH}_{2}\text{SiMe}_{3} + \underline{\text{n}}\text{-C}_{4}\text{H}_{9}\text{Cl}$$

$$\text{III}$$
(7)

two molar equivalents of \underline{n} -butyllithium per mol of $\text{Me}_3\text{SiCH}_2\text{CH=CCl}_2$. If excess \underline{n} -butyllithium is present, the alkynyllithium reagent III undergoes further metalation to give the dilithium species IV (eq. 8). Addition of trimethylchlorosilane to such reaction

$$LiC = CCH_2 SiMe_3 + \underline{n} - C_4 H_9 Li \longrightarrow LiC = CCH SiMe_3 + \underline{n} - C_4 H_{10}$$

$$Li$$

$$IV$$
(8)

mixtures results in formation of the silylation products of III and IV, Me₃SiC=CCH₂SiMe₃ and Me₃SiC=CCH(SiMe₃)₂, respectively.

Since the initial lithium reagent produced (eq. 5) is only a transient species which undergoes rapid β -elimination of lithium chloride, it is clear why, as Table 1 shows, low reaction temperatures are not required. The first lithium reagent which persists, III, is stable at room temperature.

The small amount of 2,2,6,6-tetramethy1-2,6-disila-3-chloro-3-heptene formed in the ${\rm Me_3SiCH_2CH=CCl_2/\underline{n}-C_4H_9Li/Me_3SiCl}$ reaction results from competitive Li/Cl exchange as shown in eq. 9.

Reagent V, an α -chlorovinyllithium species, is sufficiently stable for reaction with trimethylchlorosilane to take place, giving Me₃SiC(Cl)=CHCH₂SiMe₃. It is clear that the β -Cl effect on the acidity of a vinyl proton is greater than the α -silicon effect on the acidity of a methylene proton, and thus the desired chemistry (eq. 2) did not develop.

Our successful route to <u>gem</u>-chloro(trimethylsilyl)allyllithium involved the transmetalation reaction between

Ph₃PbCH₂CH=C(Cl)SiMe₃ and <u>n</u>-butyllithium. The required organolead precursor was prepared by reaction of Ph₃PbMgBr with Me₃SiC(Cl)=CH-CH₂Cl.* A similar route should, in principle, be applicable to the synthesis of Ph₃PbCH(SiMe₃)CH=CCl₂, VI, and <u>via</u> reaction of

* Such a procedure also served well in the synthesis of gem-dichloroallyllithium 10 : CCl₂=CHCH₂Cl $\xrightarrow{\text{Ph}_3\text{PbMgBr}}$ CCl₂=CH-CH₂PbPh₃ $\xrightarrow{\text{n-BuLi}}$ Li[CCl₂CHCH₂]. It is apparent that such transmetalation processes occur more readily than vinyl proton metalation β to a vinylic chlorine atom.

the latter with \underline{n} -butyllithium, of Li[Me₃SiCHCHCCl₂]. would require a suitable starting material for the preparation of the required lead compound. Allylic bromination of MegSiCHg-CH=CCl₂ might provide a route Me₃SiCHBrCH=CCl₂, whose reaction with PhaPbMgBr then would be expected to give the desired VI. However, such allylic bromination of Me₃SiCH₂CH=CCl₂ could well proceed with allylic rearrangement, giving Me₃SiCH=CHCCl₂Br rather than the desired bromide. Indeed, Corriu et al. 4 had reported that allylic bromination of allyltriphenylsilane with N-bromosuccinimide gave the rearranged bromide, Ph_SiCH=CHCH_Br. Nevertheless, we examined the allylic bromination of Me3SiCH2CH=CCl2 with N-bromosuccinimide in carbon tetrachloride in the presence of a catalytic amount of benzoyl peroxide. This reaction gave a 91% yield of a monobromination product. The NMR and IR spectra of this product, however, showed it to be Me₃SiCH=CHCCl₂Br, rather than the desired Me₃SiCHBrCH=CCl₂. Presumably, rapid rearrangement of the initially formed radical, VII, to the more stable VIII took place before bromine atom abstraction occurred.

Me₃SiCHCH=CCl₂

Me3SiCH=CHCCl2

Such allyl radical rearrangements have been discussed in a review by Walling. 11

It would appear that there is no easy route to Li[Me3SiCHCHCCl2].

EXPERIMENTAL.

General Comments. The "general comments" in the preceding paper are applicable.

Preparation of 3,3-Dichloroallyltrichlorosilane and 3,3-Dichloroallyltrimethylsilane.

a) Cl₃SiCH₂CH=CCl₂.

A two-liter, three-necked round-bottomed flask, equipped with a 500 ml pressure-equalizing addition funnel, a mechanical stirrer and a Claisen adapter fitted with a no-air stopper and a nitrogen inlet, was charged with 4.95 g (50 mmol) of CuCl, 139 ml (1.0 mol) of triethylamine (distilled from NaOH pellets) and 500 ml of diethyl ether. The addition funnel was topped with a no-air stopper and charged by syringe with 100.0 ml (1.0 mol) of 1,1,3-trichloropropene and 99.7 ml (1.0 mol) of trichlorosilane. The Claisen adapter was replaced with a reflux condenser topped with a nitrogen inlet tube and then the contents of the addition funnel were added dropwise during 80 min. while the reaction mixture was stirred and maintained at reflux. During the course of the addition the following color changes were observed: initially, olive green to colorless (after the first drops had been added) to yellow, then orange and, finally, brown. Subsequently, the addition funnel and the reflux condenser were

replaced by a glass stopper and a still head. About 400 ml of a trichlorosilane/diethyl ether mixture was distilled at 37°. The residue was transfered, under nitrogen, to a distillation flask and was trap-to-trap distilled at 0.03 mm, temperature to $\sim150^{\circ}$, into a receiver cooled with liquid nitrogen. The distillate was fractionally distilled at reduced pressure to give 85.0 g (35%) of $\text{Cl}_3\text{SiCH}_2\text{CH=CCl}_2$, bp 87-88.5° at 26 mm Hg. (Found: C, 14.99; H, 1.32. $\text{C}_3\text{H}_3\text{Cl}_5\text{Si}$ calcd.: C, 14.74; H, 1.24). NMR (CCl₄): $\delta2.49$ (d, J = 8 Hz, 2H, CH₂) and 5.87 ppm (t, J = 8Hz, 1H, =CH).

b) Me₃SiCH₂CH=CCl₂.

The reaction of 85.0 g (0.35 mol) of $\text{Cl}_3\text{SiCH}_2\text{CH=CCl}_2$ with methylmagnesium bromide in diethyl ether from 1.40 mol of magnesium, using standard Grignard alkylation procedure (non-hydrolytic work-up), gave 54.35 g (85%) of $\text{Me}_3\text{SiCH}_2\text{CH=CCl}_2$, bp 73-74° at 31 mm Hg, n²⁵D 1.4604. (Found: C, 39.47; H, 6.63; Cl, 38.77. $\text{C}_6\text{H}_2\text{Cl}_2\text{Si}$ calcd.: C, 39.35; H, 6.60; Cl, 38.71). NMR (CCl₄): δ 0.12 (s, 9H, Me₃Si), 1.65 (d, J=9Hz, 2H, CH₂) and 5.85 (t, J = 9Hz, 1H, =CH). IR(film): ν (C=C) 1615 cm⁻¹.

Reaction of 3,3-Dichloroallyltrimethylsilane with n-Butyl-lithium.

A 500 ml, three-necked Morton flask, equipped with a mechanical stirrer, no-air stopper and a Claisen adapter fitted with a low-temperature thermometer and a nitrogen inlet tube, was charged with 2.874 g (15.7 mmol) of Me₃SiCH₂CH=CCl₂ dissolved in 250 ml of THF. The solution was cooled to -91° ± 2° C* and then

a 2.57 \underline{N} solution of \underline{n} -butyllithium (17.2 mmol) in hexane was

added by syringe over a 15 min. period. The resulting clear, lavendar solution was stirred at -90°C for 30 min. and then 2.60 ml (√20 mmol) of trimethylchlorosilane was added during a 2 min. period. The reaction mixture was stirred at -90°C for 30 min. The clear, colorless solution which resulted was allowed to warm slowly to room temperature and then was hydrolyzed to a dry end-point with saturated aqueous ammonium chloride. Filtration was followed by concentration of the filtrate at reduced pressure. GLC analysis of the residue (4 ft., 20% SE-30 at 110° and 6 ft. Carbowax at 110°) showed the presence of three components. These were isolated by GLC and were identified as starting material, Me_SiCH_CH=CCl_2, 10.7 mmol, 68% recovery (by IR and NMR); $Me_3SiC \equiv CCH_2SiMe_3$, 4.08 mmol (26%), whose NMR spectrum [in CCl₄: $\delta 0.17$ (s, 18H, Me₃Si), and 1.52 ppm (s, 2H, CH2)] matched that reported for this compound by West and Jones 6; $Me_3SiC(C1) = CHCH_2SiMe_3$, 0.94 mmol (6%), $n^{25}D$ 1.4530 (lit. $n^{25}D$ 1.4529), whose NMR and IR spectra matched those of an authentic sample (cf. preceding paper1).

The results of other 1:1 $Me_3SiCH_2CH=CCl_2/\underline{n}-BuLi/Me_3SiCl$

^{*} Reaction temperatures are uncorrected. They were obtained using a pentane (total immersion type) thermometer which was immersed into the reaction mixture to a depth of $^{\circ}$ 3 cm. A stem correction of 8-10°C (to lower temperature) is appropriate.

reactions are given in Table 1.

A similar reaction was carried out in which 3.63 mmol of Me₃SiCH₂CH=CCl₂ in 200 ml of THF at 1°C was treated with 7.97 mmol of <u>n</u>-butyllithium in hexane. The caramel-colored reaction mixture was treated with 10 mmol of trimethylchlorosilane. Work-up as above, followed by GLC analysis and product isolation by GLC, showed the following compounds to be present: Me₃SiC=CCH₂-SiMe₃, 1.34 mmol (37%) and Me₃SiC=CCH(SiMe₃)₂, 0.69 mmol (19%), whose IR and NMR spectra matched the published spectra of this compound⁶, 12 [NMR (CCl₄): δ0.15 (s, 27H, Me₃Si) and 1.05 ppm (s, 1H, CH)].

Reaction of 3,3-Dichloroallyltrimethylsilane with N-Bromosuccinimide.

A 200 ml, three-necked Morton flask, equipped with a reflux condenser and a nitrogen inlet tube was charged with 8.898 g (48.6 mmol) of Me₃SiCH₂CH=CCl₂, 9.225 g (46.2 mmol) of N-bromosuccinimide, a spatula tip-ful of benzoyl peroxide and 100 ml of carbon tetrachloride. The mixture was stirred and heated at reflux for 5 hr., at which time iodide-starch paper was negative. The succinimide was filtered and the filtrate was trapto-trap distilled (room temperature at 0.03 mm Hg). The distillate was concentrated (to 75°, 33 mmHg) and the residue was trap-to-trap distilled at 0.07 mm (heat gun), to give 11.6 g (91%) of Me₃SiCH=CHCCl₂Br, n²⁵D 1.5082 (Found: C, 27.95; H, 4.36; total halogen, 56.83; C₆H₁₁Cl₂Brsi calcd.: C, 27.50; H, 4.23; total halogen, 57.56). NMR (CCl₄): δ0.23 (s, 9H, Me₃Si), 4.03

(d, J = 12Hz , 1H, Si-CH=), 6.00 ppm (d, J = 12Hz, 1H,=CHCCl₂Br). The NMR spectrum was almost superimposable with that of Me₃SiCH=CH-CBr₃. 13 IR(film): ν (C=C) 1605 sh, 1595 cm⁻¹.

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